

Nanofab Project Application Form (External User)

New/Existing Project Title:	
s this an existing project? Yes No Funding Agency:	
Are you collaborating with NIST personnel in this work or experiment: Yes No	
Name(s) of NIST Collaborator(s)	
Proposed Start/Renewal Date Proposed Budget	
How many visits needed to complete experiment: How many days per visit:	
Γime frame for entire project (months):	
Principle Investigator (Person responsible for project)	
Name:	
Title:	
Institutional Affiliation:	
Country of Citizenship :	
Email:Telephone:	
Primary Researcher (Person who would visit the Nanofab)	
Name:	
Title:	
Institutional Affiliation:	
Country of Citizenship :	
Email: Telephone:	
Co-Researcher (Any others working at the Nanofab)	
Name:	
Title:	
Institutional Affiliation:	
Country of Citizenship:	
Email:Telephone:	
(If there are additional co-researchers, attach additional forms as necessary)	
To help us better report our impact on the scientific community we request you use the space below to list the names and titles of any additional collaborators on this project even if they will be visiting the Nanofab.	not

External Project Application

There is a fee waiver available for non-proprietary external research that supports the CNST mission.

The CNST mission is to provide measurement methods, standards and technology to support all phases of nanotechnology development from discovery to production.

Non-proprietary research is not confidential, public access is permitted to the resulting data, and the research in general will be published with an acknowledgment to CNST. To be eligible for the fee waiver, the proposal must be non-proprietary and support the CNST mission if the PI is not a NIST staff member.

Is the research non-proprietary	Yes	No No	
Please clearly answer the following:			
Describe the long-term goal of your research pre-	oject.		
2. What is the expected significance of this project	et and its i	mpact on m	neasurement
methods for nanotechnology?			
3. Which aspects of this project require Nanofab c	apabilities	s?	

Photolithography	Dry etch	Furnaces	
Metal Deposition	Inspection	Wet chemistry	
Wafer saw/wire bonder	Imprint lithography	Focused ion beam	
Electron beam lithography			
4. Describe in some detail the wo	-	n the Nanofab. Specify	
5. Describe any previous results, support the work intended to be con	npleted in the Nanofab	•	
Upon acceptance of your application, pay by credit card, check or purchase		rmation. You may choose to	

Do not write below this line – For CNST use only

Date Approved:_

Date Received:_

Which tools do you plan to use?

Proposal # __